M agnetic-eld dependence of electron spin relaxation in n-type sem iconductors

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W epresent a theoretical investigation of the magnetic eld dependence of the longitudinal (T_1) and transverse (T_2) spin relaxation times of conduction band electrons in n-type III-V sem iconductors. In particular, we not that the interplay between the Dyakonov-Perel process and an additional spin relaxation channel, which originates from the electron wave vector dependence of the electron g-factor, yields a maximal T_2 at a nite magnetic eld. We compare our results with existing experimental data on n-type G aAs and make speci c additional predictions for the magnetic eld dependence of electron spin lifetimes.

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The electron spin in a sem iconductor is a robust object which can be utilized to add new functionality to existing electronic devices or to even build completely new devices based on this spin degree of freedom. [1] Establishment of successful spintronics devices requires a thorough understanding of the electron spin dynamics in a sem iconducting environment. In particular, spin relaxation processes need to be identied and controlled.

Important electron spin relaxation processes in ntype sem iconductors include the Elliott-Yafet (EY) process [2, 3], that leads to spin ip scattering and, in sem iconductors without inversion symmetry, the Dyakonov-Perel (DP) process [4], in which spin states precess because of spin o -diagonal Ham iltonian matrix elements resulting from a combination of the spin-orbit interaction and inversion asymmetry. Typically, the DP mechanism dom inates the spin dynam ics in n-type III-V sem iconductors. An external magnetic eld, in many cases required for control and manipulation in spintronics devices, can signi cantly in uence electron spin dynamics. A magnetic eld has two main e ects on electron spin relaxation: (i) it quenches the DP process thereby tending to extend the spin lifetimes as a function of the magnetic eld [5], and (ii) it opens an additional spin relaxation process which tends to reduce the spin lifetim es in applied magnetic elds. [6] The latter process is due to the wave vector dependence of the conduction band (CB) electron q-factor. As a result of the variations in the q-factor, electrons in di erent quantum states precess about a transverse magnetic eld at di erent rates and thus lose spin coherence. For brevity we will refer to this process as a variable q-factor (VG) mechanism.

In contrast to previous studies [2, 3, 4, 5, 6, 7, 8, 9, 10, 11] of spin relaxation in (bulk) n-type III-V sem iconductors, we simultaneously treat the EY, DP, and VG processes on an equal footing and focus on the interplay between the various spin relaxation processes as a function of the magnetic eld. Thereby, we are able to study in detail the competition between the quenching of the DP process and the appearance of the VG process.

Speci cally, we calculate the longitudinal (T_1) and transverse (T_2) spin relaxation times as a function of

tem perature, electron density and magnetic eld. We nd that the VG process dom inantly in uences the transverse (T_2) spin relaxation time. In particular, as a result of the competition between the quenching of the DP process and the introduction of the VG process, there is a magnetic eld for which the transverse (T_2) spin lifetim e ism axim al. From the slope of T_2 at sm all magnetic elds it is moreover possible to determ ine whether the DP or the EY process dom inates spin relaxation at zero magnetic eld. In contrast, the magnetic eld dependence of the longitudinal (T_1) lifetim e is essentially una ected by the VG process and dom inated by the quenching of the DP process. Thus, they generally increase with eld and saturate at a value given by the EY process.

In an applied magnetic eld, the CB electrons in a III-V sem iconductor, e.g. GaAs, are described by the Ham iltonian [12, 13]

$$H (\mathcal{K}) = (\mathcal{K}) + \frac{1}{2} [_{L}^{*} + _{IA}^{*} (\mathcal{K}) + _{g}^{*} (\mathcal{K})] \sim ; (1)$$

where $\mathcal{K} = \mathcal{K}$ (e=~c) $\mathcal{K}(\mathbf{r})$ $\mathcal{K}(\mathbf{r})$ is the vector potential], (\mathcal{K}) is the K ram ers degenerate dispersion of CB electrons, ~~_L = _B g B is the Larm or frequency, ~~_{IA} (\mathcal{K}) = 2 $_0$ ~(\mathcal{K}) is the splitting of the CB dispersion due to the combination of spin-orbit interaction and inversion asymmetry, and

$$\sim a_{g}(\mathcal{K}) = 2a_{4}\mathcal{K}^{2}\mathcal{B} + 2a_{5}\mathcal{K};\mathcal{B};\mathcal{K}g + 2a_{6}\sim (\mathcal{K};\mathcal{B})$$
 (2)

is a term which gives rise to a wave vector dependence of the CB electron g-factor. The de nitions of the vectors \sim (K) and \sim (K ;B) and of the parameters _____, a_i; i= 4;5;6 are given in Refs. [12, 13] and f;g indicates an anticom - m utator.

O ur calculation starts from the full quantum kinetic equations for the contour-ordered G reen functions [14], from which we derive, considering a classical hom ogeneous magnetic eld and using the fact that wave vector scattering is essentially instantaneous on the time scale of spin relaxation, a sem iclassical kinetic equation for the CB electron density matrix. We then linearize this kinetic equation with respect to the CB electron spin density, assuming, as an initial condition, small spin polarization. Treating scattering processes in the Born approximation and expanding the collision integrals up to second order in the wave vector transfer (di usion approximation [14]), we nally obtain a generalized Fokker-P lanck-Landau equation for the spin density S (Kt) which, in atom ic units (with magnetic eld along the z-axis) reads

$$[\underline{\theta}_{t} \quad \underline{i}_{c} \quad \underline{L}_{z} \quad]S \quad (\underline{K}t) = [\underline{\Gamma}_{L} + \underline{\Gamma}_{IA} \quad (\underline{K}) + \underline{\Gamma}_{g} \quad (\underline{K})] \quad S \quad (\underline{K}t) + [\underline{D} \quad \frac{1}{2_{1} \quad (\underline{K})} \quad \underline{L}^{2}]S \quad (\underline{K}t) \quad (\underline{K})S \quad (\underline{K}t); \quad (3)$$

with $_{\rm C}$ the cyclotron frequency, $\hat{\rm L_z}$ and $\hat{\rm L}^2$ the zcomponent and the squared total angularmomentum operator in wave vector space, respectively, $1 = _1$ (k) the sum of the (on-shell) wave vector relaxation rates for the various scattering processes, and $\hat{\rm D}$ a di erential operator in k = 3 j relevant to inelastic scattering processes.

Equation (3) contains EY, DP, and VG processes and accounts for Larm or precession and orbitalm otion of the CB electrons in the magnetic eld. M ore speci cally, the EY process, due to genuine spin ip scattering events, is given by the tensor , whereas the DP and VG processes originate from the interplay of spin conserving wave vector scattering events described by the di erential operator \hat{D} (1=2₁) \hat{L}^2 and the torque forces due to \sim_{IA} and \sim_{g} , respectively. The orbitalm otion encoded in i $_{c}$ \hat{L}_{z} and, to a lesser extend, the torque force due to \sim_{L} lead to a quenching of the DP process.

It is possible to derive from Eq. (3) general expressions for the spin relaxation rates without specifying whether the scattering processes are elastic ($\hat{p} = 0$) or inelastic ($\hat{p} \in 0$). To that end, we follow Ref. [4] and employ a perturbative approach with respect to the torque forces. O ur results are therefore valid for $j_{IA} + \gamma_g j_1 < 1$. Expanding γ_{IA} (\hat{k}) and γ_g (\hat{k}) in terms of spherical harm onics Y_{Im} (;), we nd (i = 1;2) [15]

$$[T_{i}]^{1} = T_{i}^{EY} + T_{i}^{DP} + T_{i}^{VG} + T_{i}^{VG}$$
(4)

with the EY contributions (due to spin-ip scattering)

$$T_1^{EY} = 2 T_2^{EY} = \frac{32}{3} C_{sf}^2 = \frac{k^4}{1 (k)}$$
; (5)

the DP contributions (due to inversion asymmetry)

$$\Gamma_{1}^{DP} = 4j\Gamma_{31}^{Y}j_{31}^{2} + 4j\Gamma_{33}^{Y}j_{33}^{2};$$
 (6)

$$\mathbb{T}_{2}^{DP} \stackrel{1}{=} 2 \hat{\mathbb{T}}_{32}^{Z} \hat{\mathbb{J}}_{32}^{3} + 2 \hat{\mathbb{T}}_{31}^{Y} \hat{\mathbb{J}}_{31}^{3} + 2 \hat{\mathbb{T}}_{33}^{Y} \hat{\mathbb{J}}_{33}^{3}; (7)$$

and the VG contributions (due to the wave vector dependence of the CB electron g-factor) $% \left({{\mathbb{F}}_{{\mathbb{F}}}^{(n)}} \right)$

$$T_{1}^{VG} = 4 \mathfrak{P}_{21}^{Y} \mathfrak{f}_{21}^{1}; \qquad (8)$$

$$T_{2}^{VG} = \mathcal{D}_{00}^{Z} \mathcal{J}_{00}^{2} + \mathcal{D}_{20}^{Z} \mathcal{J}_{20}^{2} + 2\mathcal{D}_{21}^{Y} \mathcal{J}_{21}^{3}: (9)$$

Here, C_{lm}^{i} and D_{lm}^{i} (i = X;Y;Z) are the expansion coe - cients of $_{IA}^{i}$ (k) and $_{q}^{i}$ (k), respectively, and (= 1;2;3)

$$\sim_{\rm lm} = \operatorname{RehC}_1(k)_{\rm lm}(k)i; \qquad (10)$$

where the brackets denote an average over k de ned as h (:::) i = $\begin{bmatrix} K_1 \\ 0 \end{bmatrix} dkk^2 f(k) f(k)$ (:::)=4 $\begin{bmatrix} K_1 \\ 0 \end{bmatrix} dkk^2 f(k) f(k)$, with f(k) = 1 f(k) and f(k) the equilibrium Ferm i distribution function. The generalized wave vector relaxation time $\begin{bmatrix} m \\ m \end{bmatrix}$ (k) satis es a di erential equation

$$D^{+} + i(m_{C} + L) - \frac{1}{1(k)}]_{lm}(k) = C_{1}(k);$$
 (11)

with $C_1(k) = C_{IA} k^3_{I3} + C_g(B)k^2[_{12} + _{10}], _L = _L[_1 __2], and 1=_1(k) = 1(1+1)=2_1(k)$. The constants characterizing the three spin relaxation processes are, respectively, $C_{sf} = ^2(+ 2_g)R_0m_0=2_gm$, $C_{IA} = 2_0=R_0a_0^3$, and $C_g(B) = 2_BB=R_0a_0^2$, where $^2 = 2^{-2}=(+ _g)(2 + 3_g)$, is the spin-orbit splitting, $_g$ is the band gap, R_0 and a_0 are the Rydberg energy and the Bohr radius, respectively, m and m_0 are the CB electron m ass and the m ass of a bare electron, respectively, and $_B$ is the Bohr m agenton. The detailed form of D depends on the scattering processes and does not concern us here. [15]

N ote, as a consequence of the orthogonality of the angle dependences, the EY, DP, and VG spin relaxation rates are additive. The generalized relaxation rate $1 = _{lm} (k)$, on the other hand, is in general not proportional to the sum of the (on-shell) relaxation rates $1 = _{1}(k)$ because of inelasticity. A M atthiessen-type rule for $1 = _{lm} (k)$ only holds for elastic scattering (see below).

We are interested in the magnetic eld dependence of the spin relaxation processes which, at least qualitatively, should not depend on the approximation adopted to decribe the scattering events. In the following, we treat therefore all scattering processes in the elastic approximation and neglect \hat{D} in Eq. (11). Speci cally, we take scattering on ionized in purities, acoustic phonons, and longitudinal optical (LO) phonons into account. The elastic approximation restricts our results to low enough tem peratures, where electron-impurity scattering dom inates, and to high enough tem peratures, where electronphonon scattering becom es essentially elastic.

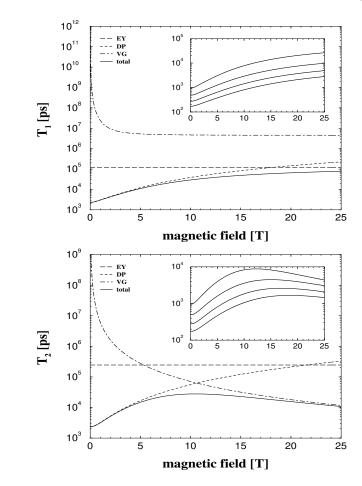


FIG. 1: The top and bottom panels show, respectively, T_1 and T_2 in G aAs as a function of magnetic eld for T = 0 and $n = 10^{18}$ cm³. The contributions from the EY (long dash), DP (short dash) and VG (dot-dash) processes and the total relaxation time (solid) are shown in the main panel. The insets (same axis as the main panel) show the total relaxation times for $n = 5 \ 10^{17}$ cm³; 1 10^{18} cm³; 5 10^{18} cm³; and 1 10^{19} cm³ (top to bottom). The squares and triangles are experimental data from Ref.[19] at the respective densities.

10

magnetic field [T]

10¹⁰

10⁹

10⁸

10

10⁶

10⁵

10⁴

10³

10²

10⁸

10

10⁶

10⁵

10⁴

10³

10²

 Γ_2 [ps]

0

5

5

EY

DP VG

 T_1 [ps]

DP VG 10⁴

10³

10²

10¹

10

ō

10

10

10

10

10¹

10

magnetic field [T]

20

20

20

20

25

25

25

10 15

15

15

W ithin the elastic approximation Eq. (11) reduces to an algebraic equation which is readily solved to yield

$$\sim_{\rm Im} = \frac{1}{(k)} \left(\frac{C_{\rm IA}^2 k^6}{1 + [(m_{\rm C} + L_{\rm I})]^2} (B) k^4 (L_{\rm I2} + L_{\rm I0}) \right)^{+} (12)$$

The k-average can be obtained either num erically or, at low and high tem peratures, with saddle point techniques exploiting the peaked structure of the integrands. Within the elastic approximation it is su cient to adopt the latter. D etails of the calculation will be given elsew here. [15]

In Fig. 1, we show calculated longitudinal (T_1) and transverse (T_2) spin relaxation times for G aAs as a function of magnetic eld at T = 0 and an electron density of $n = 10^{18}$ cm³. We show separately the contributions to the spin relaxation times from the EY, DP

FIG. 2: The top and bottom panels show, respectively, T_1 and T_2 in G aAs as a function of magnetic eld for T = 100K and $n = 10^{17}$ cm³. The contributions from the EY (long dash), DP (short dash) and VG (dot-dash) processes and the total relaxation time (solid) are show n in the main panel. The insets (same axis as the main panel) show the total relaxation tim es for T = 150K;200K;250K; and 300K (top to bottom).

and VG processes and the total spin relaxation time including all three spin relaxation processes. In the insets of Fig. 1, we give the total spin relaxation time for various electron densities at T = 0. The parameters needed to specify \sim_{g} (K) have been previously obtained partly experimentally by measuring combined cyclotron resonances (a₄;a₆) and partly theoretically within a velevel K ane model (a₅): (a₄;a₅;a₆) = (97; 8;49) 10²⁴ eV cm²O e¹. [13] The parameter de ning \sim_{IA} (K) is given by $_{0} = 0.06 \sim^{3} = 10^{10} (2m)^{3} g$. [16] The remaining parameters, such as the elective CB electron mass or the deformation potential are available from standard data bases. [17]

For the tem perature and density conditions in Fig. 1, the electrons are degenerate and electron-ionized im purity scattering dom inates. The VG process makes a sm all contribution to T_1 which is dom inated by the DP process at zero magnetic eld. A s the magnetic eld is increased, the DP process is quenched. Thus, T_1 increases monoton-

ically with increasing magnetic eld saturating at high eld at a value determ ined by the EY process which is not a ected by the magnetic eld. [18] If the material param eters had been such that the EY process dom inated the DP process for T_1 relaxation at zero magnetic eld, T₁ relaxation would not be signi cantly a ected by the applied eld. By contrast the VG process makes a signi cant contribution to T_2 relaxation. At sm all applied magnetic elds the T₂ lifetime increases with increasing magnetic eld, but as the eld continues to increase the VG process begins to dom inste the relaxation so that T_2 has a maximum and begins to decrease for larger magnetic elds. If the material parameters had been such that the EY process dom insted the DP process for T_2 relaxation at zero magnetic eld, the T_2 relaxation would m onotonically decrease with increasing magnetic eld.

The solid squares and triangles in the lower panel of Fig. 1 are measured T_2 spin lifetimes in GaAs at 5K from Ref. [19] at electron densities of 1 10^{18} cm⁻³ and 10^{18} cm 3 . (D ata for an electron concentration of 5 10^{16} cm 3 at 5K was also presented in Ref. [19], but 1 at this low density the electrons are bound to isolated donors and our theory does not apply.) There is good (order of m agnitude) agreem ent between our calculation and these measured results, although there were no adjustable parameters. Unfortunately, the magnetic elds in Ref. [19] are not high enough to capture any e ects due to the VG process. In particular, our prediction of the maximum of T2 remains to be experimentally veried.

In Fig. 2, we show the various contributions to the T_1 and T_2 spin relaxation for GaAs as a function of magnetic eld at T = 100K and an electron density of $n = 10^{17}$ cm³. In the insets of Fig. 2, we show the total spin relaxation time as a function of magnetic eld for various tem peratures at $n = 10^{17}$ cm³. For the tem perature and density conditions in Fig. 2, the electrons are non-degenerate and electron-LO-phonon scattering is the dom inant scattering process. As for the degenerate electron case, the VG process makes a small contribution to T_1 which is again dom inated by the DP process at zero

magnetic eld. The DP process is quenched by the eld so that T₁ increases with eld at small elds and saturates at a value determ ined by the EY process at large elds. [18] Similar to the degenerate electron case, the VG process makes a substantial contribution to T₂ relaxation. At small elds the T_2 lifetime increases with increasing eld and at large elds the VG process begins to dom inste the relaxation so that T_2 has again a maximum at some nite magnetic eld. The sign of the slope in T₂ at sm all m agnetic elds is again a clear signature of whether the EY process (T2 decreases with increasing eld) or DP process (T2 increases with increasing eld) dom inates T_2 relaxation at zero m agnetic eld. Note, the qualitative behavior of the longitudinal and transverse spin relaxation times with increasing magnetic eld is sim ilar for degenerate and non-degenerate electrons, but the magnitude of the change is larger for non-degenerate electrons.

In summary, based on a system atic kinetic approach, which treats the EY, DP, and VG processes on an equal footing, we calculated the longitudinal (T_1) and transverse (T_2) spin relaxation times of CB electrons in n-type III-V sem iconductors as a function of tem perature, electron density, and magnetic eld. At nite magnetic eld, the VG process competes with the DP and EY processes. We nd that, as a consequence of the interplay of the DP and the VG processes, T_2 can have a maximum as a function of magnetic eld. In contrast, T_1 is not a ected by the VG process and increases with magnetic eld until it saturates at a value determ ined by the EY process. The sign of the change in T_2 with increasing magnetic eld at sm all elds indicates, m oreover, whether the EY process or the DP process dom inates T₂ relaxation at zero m agnetic eld. Our calculated results are in good agreem ent with existing experim ental data in n-type G aA s and we make additional speci c predictions for the magnetic eld dependence of electron spin lifetim es that are subject to experim ental check.

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